## **AMENDMENTS TO THE CLAIMS**

This listing of claims replaces all prior versions of claims in the application.

## **Listing of Claims**

Claims 1-20 (cancelled)

Claim 21 (new): A method for fabricating a ceramic substrate comprising the steps of: providing a base;

forming a first basic layer, comprising a first layer and a second layer, wherein the first layer is formed by:

screen-printing a first dielectric material in a first region of the base; and screen-printing a second dielectric material in a second region of the base other than the first region, the first dielectric material having a dielectric constant different from that of the second dielectric material;

wherein the second layer is formed by screen-printing directly on the first layer;

forming a second basic layer directly on the second layer of the first basic layer, the second basic layer is formed by:

screen-printing a third dielectric material in a third region on the second layer, and

screen-printing a fourth dielectric material in a fourth region on the second

layer other than the third region;

releasing the first basic layer from the base; and

sintering the first basic layer and the second basic layer.

Claim 22 (new): The method for fabricating a ceramic substrate according to claim 21,

wherein a first dielectric layer formed from the first dielectric material has a dielectric constant

different from that of a third dielectric layer formed from the third dielectric material.

Claim 23 (new): The method for fabricating a ceramic substrate according to claim 21,

further comprising screen-printing a fifth dielectric material in a fifth region of the base at a

periphery of the first region, to form a stress mitigating layer.

Claim 24 (new): The method for fabricating a ceramic substrate according to claim 23,

wherein the fifth dielectric material comprises at least one component of the first dielectric

material and at least one component of the second dielectric material.

Claim 25 (new): The method for fabricating a ceramic substrate according to claim 21,

further comprising screen-printing a conductor paste in a sixth region of the base, to form a via.

Claim 26 (new): The method for fabricating a ceramic substrate according to claim 25,

wherein the conductor paste is screen-printed before the second dielectric material is screen-

Page 4

printed.

Claim 27 (new): The method for fabricating a ceramic substrate according to claim 25,

wherein further comprising screen-printing a conductor paste on the first basic layer to form a

conductor layer.

Claim 28 (new): The method for fabricating a ceramic substrate according to claim 27,

further comprising, after the step of forming the conductor layer, pressurizing the first basic layer

at the surface where the conductor layer is formed to planarize the surface of the first basic layer,

where the conductor layer is formed.

Claim 29 (new): The method for fabricating a ceramic substrate according to claim 27,

wherein the conductor layer forms a circuit connected to a first dielectric layer formed from the

first dielectric material, the circuit having at least two functions of a transmission interconnection

circuit, antenna, a low-pass filter, a high-pass filter, a band-pass filter and a capacitor.

Claim 30 (new): The method for fabricating a ceramic substrate according to claim 21,

wherein the second dielectric material is in powder or paste and screen-printed to surround a first

dielectric layer formed from the first dielectric material.

Claim 31 (new): The method for fabricating a ceramic substrate according to claim 21,

Page 5

Amendment

Application No. 10/724,615

Attorney Docket No. 032152

further forming conductor layers on and below a first dielectric layer formed from the first

dielectric material, to form a passive element in the region where the first dielectric layer is

formed.

Page 6